

AMAT AKT 1600

PECVD process iN, SiO₂, i-a-Si, SiON and N+ a-Si

SN 6C102



All information contained herein is strictly confidential

AMAT AKT 1600 PECVD

Dielectric Process, SN 6C102

Location: Warehouse Nijmegen / Condition: un-refurbished

- Tool Model : AMAT 1600 PECVD
- Tool Serial Number : 6C102
- Vintage 2005
- Process: PECVD iN, SiO₂, i-a-Si, SiON and N+ a-Si
- Software Version: AKT7.3
- System Power Rating: 208 VAC 3-Phase
- Flat panel size: 320 x 352 mm
- (5) Process chambers:
 - Film Capability SiN
 - SiO₂
 - i-a-Si
 - SiON
 - N+ a-Si (Remote Plasma Clean)

Includes:

- Chillers



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